IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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| Applica | tion No.: 10/698,564 |) Examiner: Elena TSOY |
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| P.O. Bo | ssioner for Patents | |
| Sir: | | |
| | Amendment & Remarks Entered with | Request For Continued Examination |
| r | This paper responds to the outstanding O | ffice action dated 07-17-2007. It follows the |
| Notice o | of Appeal filed 01-17-2008. It is timely a | as it is filed with and RCE and within the period |
| for reply | y ending 04-17-2008 and accompanied by | y an extension of time and the appropriate fees |
| (\$405 for RCE & \$60 for EOT totaling \$465). The following is a table of contents. | | |
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